

Twisted Epitaxy of Ag Nanoparticles Confined Between Misoriented MoS₂ Bilayers

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Twisted epitaxy is a recently identified phenomenon in metal–2D van der Waals heterostructures, first observed in the Au–MoS₂ system, where epitaxial nanoparticles reorient under the influence of a controlled twist between encapsulating layers. Here, we investigate the extension of this effect to the Ag–MoS₂ system, motivated by the chemical similarity, comparable atomic radius, and crystal structure of silver and gold.

Using high-resolution through-foil transmission electron microscopy (TEM), we examine Ag nanoparticles confined between two mechanically exfoliated MoS₂ layers with a predefined twist angle (0–60°) and subjected to annealing at 500 °C. Initially, the nanoparticles adopt an epitaxial relationship with the bottom MoS₂ (0001) substrate (Ag $\langle 220 \rangle \parallel \langle 1\bar{1}20 \rangle$ MoS₂). Upon annealing, they undergo pronounced morphological and structural evolution. For bilayer twist angles up to ~10°, a gradual reorientation toward an intermediate alignment between the top and bottom MoS₂ lattices is observed. At larger twist angles, the Ag nanoparticles exhibit only minor deviations (~2°) from their initial epitaxial orientation.

Compared to the Au–MoS₂ system, the Ag–MoS₂ heterostructure displays a broader range of twist responses and more complex reorientation behavior. These results demonstrate that twisted epitaxy is not limited to Au-based systems but is likely a more general phenomenon applicable to a wider class of metal–2D material heterostructures.